



بِسْمِ اللَّهِ الرَّحْمَنِ الرَّحِيمِ



شبكة المعلومات الجامعية التوثيق الالكتروني والميكروفيلم



شبكة المعلومات الجامعية

جامعة عين شمس

التوثيق الالكتروني والميكروفيلم

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COMPUTER BASED CONTROL SYSTEM FOR THE DOUBLE EFFECT EVAPORATOR PROCESS

by

Eng. Ahmad Eissa Hussien Hasan
Assistant Researcher – Pilot Plant Dept.
National Research Centre

A Thesis submitted to the
Faculty of Engineering at Cairo University
in Partial Fulfillment of the
Requirements of the Degree of
DOCTOR OF PHILOSOPHY

in

ELECTRICAL POWER AND MACHINES

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27/1/2000

09/11
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ACKNOWLEDGMENT

In this lines I wish to express my thanks for every body who offered help in this work. First of all I thank **GOD** who granted me power to complete this work.

I wish to express my deepest gratitude to **Professor Dr. Adel Abd-Elraoof Hanafy** , Profssor of Control Engineering , Faculty of engineering, Cairo University, for his kind supervision, resoursable knowledge and encouragement which have truly helped in bringing this work to a successful end.

I pray to **GOD** to forgive **Professor Dr. A.M.Eltobshi** , asking **GOD** to keep him in the high degree in the **Paradise**.

I wish to express my appreciation to **Professor Dr. Abd-Elghany Gamal Abu-elnour** , Professor of Chemical Engineering , National research Centre, Cairo , for helpful interest and encouragement.

I also wish to express my thank to **Dr. M.I.Kamel** , Benha Institute Of Technology for his help.

I also wish to express my thanks to the staff members of Pilot Plant Department in National Research Centre for their cooperation.

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